

<b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>				Complete if Known	
				Application Number	10/517,491
				Filing Date	December 20, 2004
				First Named Inventor	KAULE
				Group Art Unit	2872
				Examiner Name	Lavarias
				Confirmation No.	5564
Sheet	1	of	3	Attorney Docket Number	2732-149

U.S. PATENT DOCUMENTS					
Examiner Initials*	Cite No. <sup>1</sup>	U.S. Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY
		Number	Kind Code <sup>2</sup> (if known)		
/ACL/	1	6,088,161		Lee	06-11-2000
/ACL/	2	5,825,547		Lee	10-20-1998

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

<sup>1</sup>Unique citation designation number. <sup>2</sup>See attached Kinds of U.S. Patent Documents. <sup>3</sup>Enter Office that issued the document, by the two-letter code. <sup>4</sup>For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. <sup>5</sup>Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. <sup>6</sup>Applicant is to place a check mark here if English language translation is attached. AB indicates that only an English language abstract is attached.

/Arnel C. Lavarias/ 11/02/2009

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FOREIGN PATENT DOCUMENTS							
Examiner Initials*	Cite No. <sup>1</sup>	Foreign Patent Document			Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	T <sup>6</sup>
		Office <sup>3</sup> Code	Number <sup>4</sup>	Kind <sup>5</sup> (if known)			
/ACL/	3	WO	94/14621	A1	Gao Gesellschaft fur Automation und Organisation mbH	07-07-1994	AB
Examiner Signature	/Arnel C. Lavarias/				Date Considered	11/02/2009	

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NON PATENT LITERATURE DOCUMENTS				
Examiner Initials*	Cite No. <sup>1</sup>	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	T <sup>2</sup>	
/ACL/	4	RAI-CHOUDHURY, P., "SPIE handbook of microlithography, micromachining and microfabrication", <i>Handbook of Microlithography, Section 2.5 Systems</i> , 16 pages, 1997		
Examiner Signature	/Arnel C. Lavarias/		Date Considered	11/02/2009

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